Temperature-Programmed Reduction of Oxidic and Sulfidic Alumina-Supported NiO, WO₃, and NiO-WO₃ Catalysts

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Received January 13, 1993; revised August 18, 1993

The reduction behaviour of oxidic and sulfidic alumina-supported Ni, W, and NiW catalysts has been studied using temperature-programmed reduction (TPR). Besides giving structural information on the oxidic and sulfidic state, the TPR patterns gave detailed information on the sulfidability of the various oxidic species. From the oxidic species only dispersed NiO was completely sulfidable at 673 K, whereas the other species were partly sulfidable (mixed Ni-W phase, dispersed WO3, and Ni in the surface alumina layer) or not sulfidable (Ni in subsurface alumina layers and NiWO₄). The sulfided catalysts contained at least four types of sulfur, viz. stoichiometric sulfur behaving as S in a bulk analogue (WS2, Ni3S2, NiS1+r) or in NiWS (NiWS is not directly observed under TPR conditions due to sintering into Ni₃S₂ and WS₂), a reactive type of sulfur indicated as Sx, S-H groups, and adsorbed H₂S. Except NiS_{1+x} and S_x, no sulfided phase reduces under HDS conditions. Although hydrogenation of sulfur might well be an elementary step in the desulfurisation reaction, only a weak correlation was observed between the HDS activity and the reduction rate of the Sr species. © 1994 Academic Press, Inc.

INTRODUCTION

Alumina-supported molybdenum and tungsten catalysts, which contain Ni or Co as promoter, are commonly applied for hydrodesulfurisation and hydrodenitrogenation processes. Cobalt-promoted catalysts are mainly used for the removal of sulfur, whereas Ni-promoted catalysts are superior in denitrogenation and hydrogenation reactions. Most studies have been devoted to CoMo and NiMo catalysts. NiW catalysts have not drawn much attention for two reasons: first, they are applied less frequently and, secondly, they may be expected to exhibit similar structural features to the NiMo and CoMo catalysts (W and Mo, and Co and Ni are chemically related). In the relatively few studies devoted to oxidic and sulfidic NiW catalysts, comparable structures to those in CoMo and NiMo catalysts were indeed observed (1–10). How-

ever, distinct differences with respect to sulfidability and reducibility of the various species on NiW and CoMo catalysts have also been reported (see Refs. 7, 11–13). Moreover, at high calcination temperatures, the speciation of Ni and Co largely differed in NiW and CoMo catalysts, respectively (7, 12). Since the catalysts are activated by a sulfiding step, it is interesting to study the extent of sulfiding of the various oxidic species and the structure of the catalysts after treatment at commonly applied sulfiding temperatures.

Scheffer et al. (14) showed that detailed information on the structure and sulfidability of the various oxidic species can be obtained by the temperature-programmed reduction (TPR) technique. Comparison of the reduction patterns of oxidic and sulfidic catalysts makes it possible to draw conclusions about the sulfidability of the various oxidic species. Since the reduction agent in TPR is hydrogen, the reactivity of the various sulfidic species in TPR are related to the reactivity of these species under hydrotreating conditions. Consequently, it is tempting to investigate whether a relation exists between the reduction rate of the various sulfidic species and the hydrotreating activity of the various catalysts.

EXPERIMENTAL

The model compound nickel(II)sulfide (Johnson Matthey Gmbh) was studied as supplied, whereas tungsten sulfide (Alfa Inorganics Ventron) was treated with H₂S at 673 K, since the sample had been partially reoxidised during storage.

The catalysts were prepared by pore-volume impregnation of a γ -alumina support (Ketjen 000-1.5E high purity, surface area 200 m²/g, particle size $100-150\times10^{-6}$ m and pore volume 0.5 cm³/g). The alumina-supported tungsten (W/Al) catalysts were prepared using solutions of ammonium tungstate (NH₄)₆H₂W₁₂O₄₀ · xH₂O (Pfaltz and Bauer). After the catalysts were dried at 323 K for 7.2×10^3 s and at 373 K for 54×10^3 s, they were subsequently calcined at 773 K for 7.2×10^3 s in dried air (40 μ mol/s). The alumina-supported nickel (Ni/Al) catalysts were

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TABLE 1

Alumina-Supported Tungsten (W/Al),
Nickel (Ni/Al), and Nickel-Tungsten
(Ni/W/Al) Catalysts

	Weight content (%)				
Catalyst code	NiO	WO ₃			
W(2.4)/Al		15.6			
Ni(0.85)/Al	2.0	_			
Ni(1.7)/Al	4.0	_			
Ni(2.6)/Al	6.0				
Ni(1.0)/W(2.3)/Al	2.0	15.2			
Ni(2.0)/W(2.3)/Al	4.0	14.9			
Ni(2.9)/W(2.3)/Al	5.8	14.6			

prepared by successive additions of the equivalent of 2 wt.% NiO by pore-volume impregnation of Ni(NO₃)₂·6H₂O (Janssen Chimica). After each impregnation step, the catalysts were dried and calcined in a procedure similar to that described for the W/Al catalysts. After the final impregnation step, the catalysts were calcined at 773 or 1073 K. The Ni-W/Al catalysts were prepared in the same way starting from W/Al catalysts containing 15.6 wt.% WO₃. The catalysts are denoted by the number of metal atoms per nm² of initial support area, followed by the temperature of calcination, e.g., Ni(2.9)/W(2.3)/Al-773 contains 5.8 wt.% NiO and 14.6 wt.% WO₃, and was calcined at 773 K. The catalysts are listed in Table 1.

The TPR-S equipment has been described in detail elsewhere (14, 15). Preceding the reduction step, the catalysts have been sulfided in situ in a mixture of 15 vol% H₂S in H₂. The sulfiding procedure consisted of the following steps. After flushing the quartz reactor with Ar at room temperature for 900 s, the reactor was switched to the sulfiding mixture. After sulfiding at room temperature for 900 s, the reactor temperature was raised to the final temperature with a heating rate of 0.167 K/s. All catalysts were sulfided at 673 K except for W(2.4)/Al which was sulfided at various temperatures. After sulfiding (673 K, 7.2×10^3 s), the reactor was switched to purified Ar and purged for 1.8×10^3 s. Subsequently, the reactor was cooled to room temperature. When higher sulfiding temperatures were applied, the reactor was cooled to 673 K in the sulfiding mixture and subsequently purged in Ar, as described above. The W(2.4)/Al catalyst, which was sulfided at 573 K, was purged at this temperature for 1.8 \times 10³ s and subsequently cooled to room temperature. As soon as the reactor reached ambient temperature (after about 600 s) the reactor was switched to H₂/Ar (67 vol% H₂ in Ar). When the TCD signal was stabilised (3.6- 7.2×10^3 s) the sample was reduced at a heating rate of 0.167 K/s up to 1270 K. The H₂S production was detected with a UV-spectrophotometer (Perkin-Elmer C75, set at 195 nm). The H₂ partial pressure was measured after H₂S and H₂O were trapped in an oxidic CoMo/Al catalyst and a molecular sieve, respectively. Since organic material adsorbs on the catalysts (16), a FID detector was applied to measure the CH₄ production. In quantitative analyses the TCD signal was corrected for the CH₄ peaks.

To distinguish between reduction of sulfidic and oxidic samples the abbreviations TPR-S and TPR are used for temperature programmed reduction of sulfidic and oxidic catalysts, respectively. The TPR experiments were carried out similarly to TPR-S.

RESULTS

Bulk Compounds

NiS. The TPR-S pattern of NiS is shown in Fig. 1a. The $\rm H_2$ consumption and $\rm H_2S$ production are closely matched. The patterns are dominated by two large peaks, viz., a peak between 600 and 900 K (maximum at 790 K) and a broad peak between 900 and 1270 K. The second peak shows a distinct shape since the reduction rate slowly increased up to 1200 K and then suddenly decreased to nil in a short period of time. Two small peaks are superimposed on these large peaks at about 840 and 970 K. The total $\rm H_2S$ production and $\rm H_2$ consumption agreed with complete reduction of NiS to Ni⁰.

 WS_2 . The TPR-S pattern of WS_2 is shown in Fig. 1b. Most of the reduction took place between 1000 and 1270 K; the reduction rate increased exponentially up to 1270 K, stayed nearly constant, and suddenly dropped to zero upon depletion of S (not shown). The H_2 consumption

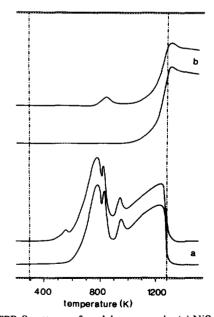


FIG. 1. TPR-S patterns of model compounds. (a) NiS, (b) WS₂. UV signal (lower curve) and TCD signal (upper curve) are shown.

and H₂S production were equal in this temperature region. The small H₂ consumption peak observed around 820 K is ascribed to the reduction of an oxidic species since no H₂S production is observed simultaneously.

The TPR patterns of the model compounds NiO, WO₃, NiAl₂O₄, Al₂(WO₄)₃, and NiWO₄ have already been presented elsewhere (7).

Catalysts

Combination of TPR and TPR-S allows a detailed discussion on the sulfidability of the various phases present. TPR measurements of Ni/Al and Ni/W/Al have been reported before by Scheffer *et al.* (7). However, since the detailed structure of the Ni catalysts strongly depends on the method of preparation, the TPR patterns of Ni/Al and Ni/W/Al catalysts are also included.

The TPR-S patterns are divided into three regions, viz. I, II, and III. Region I encloses the temperature region up to 500-600 K, region II the temperature region from 500-600 K to 800-900 K, and region III ranges from 800-900 K up to the end of the temperature program.

W(2.4)/Al. The TPR patterns were in agreement with earlier results (7, 17). Reduction of the WO₃ species takes place between 1050 and 1270 K. Since these TPR patterns are hardly affected by the preparation procedure, they are not included in this paper.

The TPR-S patterns of W(2.4)/Al, sulfided at various temperatures, are shown in Fig. 2. In all cases the H₂S production is lower than the H₂ consumption. This difference decreases for catalysts sulfided at higher temperatures. In Table 2, it is shown that an increase of the sulfiding temperature from 573 to 873 K resulted in an increase of the degree of sulfiding from 24 to 95%. The peak maximum of both TCD and UV peaks in region III shifted to higher temperatures with increasing sulfiding temperature.

The amount of H_2S producted in region II was in all cases larger than the H_2 consumption; both signals decreased with increasing sulfiding temperature. A third H_2S production and associated H_2 consumption peak are observed in region I (about 440 K). These peaks are ascribed to a reduction process ($H_2 + S \rightleftharpoons H_2S$). The intensity of the peak increased with increasing sulfiding temperature. A fourth peak is observed below 400 K. Since no H_2 consumption is observed in this temperature region, the H_2S production is ascribed to a desorption process.

Ni(x)/Al. By comparison of the TPR and TPR-S patterns which are shown in Figs. 3 and 4, respectively, the sulfidability of the various oxidic species can be determined reliably. Quantitative TPR data are given in Table 3. In the TPR-S patterns of the three Ni(x)/Al-773 catalysts, the TCD signal (H_2) is much larger than the UV signal (H_2S) , showing that a large fraction of the NiO is

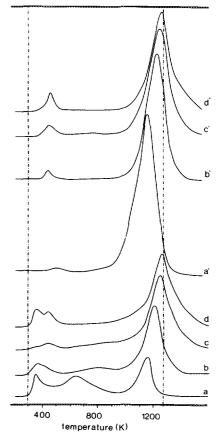


FIG. 2. TPR-S pattern of W(2.4)/Al-773 sulfided at various temperatures. (a) $T_{\text{sulf.}} = 573 \text{ K}$, (b) $T_{\text{sulf.}} = 673 \text{ K}$, (c) $T_{\text{sulf.}} = 773 \text{ K}$, (d) $T_{\text{sulf.}} = 873 \text{ K}$. UV signal (lower curves, a–d) and TCD signal (upper curves, a'–d') are shown.

not sulfidable at 673 K, which is the upper limit of common sulfiding temperatures. Comparison of the TPR and TPR-S patterns shows that the $\rm H_2$ peak around 1000–1100 K is not changed upon sulfiding. In contrast, the height of the $\rm H_2$ peak between 650 and 850 K decreased as a result of sulfiding, but did not disappear completely. Table 3 shows that the total amount of $\rm H_2S$ produced in regions II and III is at most 50% of the amount of $\rm H_2$ consumed.

A striking feature in the TPR-S patterns is a TCD peak at about 500 K which is absent in the TPR spectra. This H_2 peak is accompanied by a H_2 S peak of comparable size. The peak heights both increased with increasing NiO content, but normalized to the amount of Ni they decreased.

The H_2 consumption peak below 800 K in the TPR pattern, which was coupled to a FID signal, is ascribed to the reduction of organic material adsorbed on the surface of the catalyst. This finding illustrates that it is necessary to use a FID detector besides a TCD.

The TPR and TPR-S patterns of the Ni(x)/Al-1073 are shown in Figs. 5 and 6, respectively. They differ profoundly from the catalysts calcined at 773 K. Remarkably,

Sulf. temp Catalysts (K)	Sulf tomm	Amount W	Region I (μmol)		Region II (µmol)		Region III (µmol)		Sulf.a
	(µmol)	H ₂ S	H ₂	H ₂ S	H ₂	H ₂ S	H ₂	(%)	
W(2.4)/Al-773	573	67	8.7	~0	41	~0	29	182	24
W(2.4)/Al-773	673	67	12	3.6	16	~0	88	153	67
W(2.4)/Al-773	773	67	6.6	7.0	15	~0	108	141	83
W(2.4)/Al-773	873	67	17	8.1	~0	~0	126	137	95

TABLE 2
H₂S Production and H₂ Consumption in TPR-S of W(2.4)/Al Catalysts Sulfided at Varying Temperature

Note. The data are normalised to 0.1 g of catalyst.

in temperature region III the TCD signal of the TPR and TPR-S patterns are exactly the same and no H_2S production is observed in the TPR-S pattern. Analogous to the TPR-S patterns of Ni(x)/Al-773, a UV and TCD signal are observed in temperature region I. However, they differ in two respects: (i) the UV signal consists of two peaks, one of which coincided with a TCD peak and (ii) the peaks are smaller.

Ni(x)/W(2.3)/Al. The TPR and TPR-S patterns of the Ni(x)/W(2.3)/Al-773 catalysts are shown in Figs. 7 and 8, respectively. The quantitative data of the TPR-S measurements are listed in Table 4.

The TPR-S patterns show that the integrated H₂ consumption is larger than the H₂S production for all three catalysts, showing that none of the catalysts is completely

sulfided at common sulfiding temperatures (<673 K). In temperature region III two overlapping peaks are present, one at 1200 K and the other around 1050 K. It is striking that the H_2S production at 1200 K is independent of the Ni content whereas the H_2 consumption decreases with increasing Ni content. The height of both the H_2S and H_2 peaks around 1050 K increases with increasing Ni content. Similar to the W(2.4)/Al-773 catalyst, the amount of H_2S produced in region II is higher than the corresponding H_2 consumption. In region I a H_2 consumption and H_2S production peak are observed at 410 K (similar peaks are located at about 440 and 500 K for W(2.4)/Al and Ni(x)/Al, respectively).

The TPR and TPR-S patterns of the Ni(x)/W(2.3)/Al-1073 catalysts are shown in Figs. 9 and 10, respectively. The quantitative data of the TPR-S measurements are

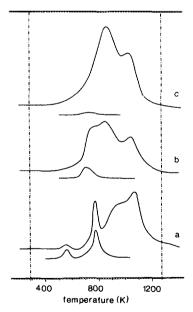


FIG. 3. TPR patterns of Ni(x)/Al-773 catalysts. (a) Ni(0.85)/Al-773, (b) Ni(1.7)/Al-773, (c) Ni(2.6)/Al-773. FID signal (lower curve) and TCD signal (upper curve) are shown.

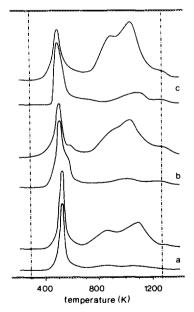


FIG. 4. TPR-S patterns of Ni(x)/Al-773 catalysts sulfided at 673 K. (a) Ni(0.85)/Al-773, (b) Ni(1.7)/Al-773, (c) Ni(2.6)/Al-773. UV signal (lower curve) and TCD signal (upper curve) are shown.

^a The degree of sulfiding is calculated based on the amount of H_2S produced and H_2 consumed in temperature region III, as follows: sulfiding degree = 100(1 - ((x - y)/3z)); x = amount of H_2S , z = amount of W.

TABLE 3
H ₂ S Production and H ₂ Consumption in TPR-S of Sulfided Ni(x)/Al Catalysts Calcined at 773 and 1073 K

Catalysts	Sulf tomm	Amount Ni (µmol)	Region I (μmol)		Region II (µmol)		Region III (µmol)		S. 16 a
	Sulf. temp (K)		H ₂ S	H ₂	H ₂ S	H ₂	H ₂ S	H ₂	Sulf.ª (%)
Ni(0.8)/Al-773	673	27	12	13	6.4	~0 ^b	6.0	23	24
Ni(0.8)/Al-1073	673	27	12	2.9	~1.2	~0	~0	30	~0
Ni(1.7)/Al-773	673	53	19	15	~0	$\sim 0^b$	17	45	48
Ni(1.7)/Al-1073	673	53	13	8.4	1.9	~0	~0	53	~0
Ni(2.6)/Al-773	673	80	17	19	8.2	$\sim 0^b$	26	59	54
Ni(2.6)/Al-1073	673	80	12	8.9	4.1	~0	~0	80	~

Note. The data are normalised to 0.1 g of catalyst.

collected in Table 4. On the basis of these data it is concluded that calcination at 1073 K strongly decreased the sulfidability of these catalysts. By comparing the TPR-S and TPR patterns it is clear that sulfiding at the higher temperatures results in a decrease of the TCD signal at 1200 K while between 1050 and 1100 K, it only slightly decreased. With increasing Ni content, the H₂S production peak at 1200 K decreased whereas the H₂S production at about 1050 K increased. The H₂S production in region II is larger than the associated H₂ consumption. In region

I of the TPR-S pattern a H₂ consumption and an associated H₂S production are observed at about 430 K.

DISCUSSION

Clearly, the system is quite complex. The TPR patterns strongly depend on the specific pretreatment conditions and the loading of the catalysts. Use of both TCD and FID detectors enables correction to be made of the patterns for hydrogenation of carbonaceous material, which is always

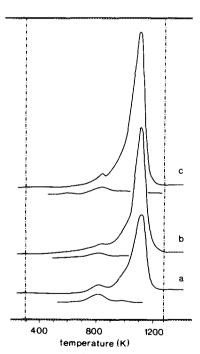


FIG. 5. TPR patterns of Ni(x)/Al-1073 catalysts. (a) Ni(0.85)/Al-1073, (b) Ni(1.7)/Al-1073, (c) Ni(2.6)/Al-1073. FID signal (lower curve) and TCD signal (upper curve) are shown.

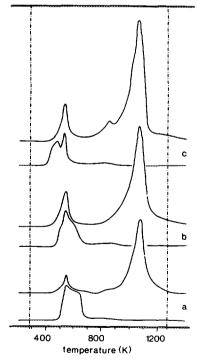


FIG. 6. TPR-S of Ni(x)/Al-1073 catalysts sulfided at 673 K. (a) Ni(0.85)/Al-1073, (b) Ni(1.7)/Al-1073, (c) Ni(2.6)/Al-1073. UV signal (lower curve) and TCD signal (upper curve) are shown.

^a The degree of sulfiding is calculated based on the amount of H_2S produced and H_2 consumed in temperature region III, as follows: sulfiding degree = 100(1 - ((x - y)/z)); x = amount of H_2 , y = amount of H_2 , z = amount of z = amo

^b The H₂ consumption between 700 and 800 K is included in region III.

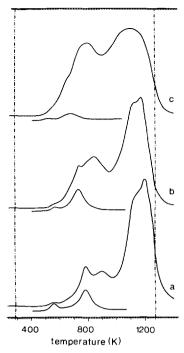


FIG. 7. TPR patterns of Ni(x)/W(2.3)/Al-773 catalysts. (a) Ni(1.0)/W(2.3)/Al-773, (b) Ni(2.0)/W(2.3)/Al-773, (c) Ni(2.9)/W(2.3)/Al-773. FID signal (lower curve) and TCD signal (upper curve) are shown.

present. In TPR-S the H_2S and H_2 were detected by a UV and TCD detector, respectively. In this way the patterns can be resolved into the different processes occurring:

- (i) H₂S desorption (UV signal without TCD signal).
- (ii) -S- hydrogenation (UV signal associated with a TCD signal).
 - (iii) -O- hydrogenation (TCD signal, no UV signal).
- (iv) C hydrogenation (TCD signal associated with FID signal, no UV signal).

Bulk Compounds

NiS. Several nickel sulfides can be formed when NiS is exposed to hydrogen, viz., Ni_6S_5 , Ni_3S_2 , and $Ni_3S_{2\pm x}$ (18). Deconvolution of the complex patterns is not straightforward, but it does not disagree with reduction of NiS to Ni_3S_2 below 850 K and subsequent reduction to Ni^0 in the high temperature region. It was shown by Scheffer et al. (14) and Mangnus et al. (15) that the reduction of metal sulfides under commonly applied TPR conditions is in many cases determined by thermodynamics. To check whether this is the case here, the H_2S/H_2 ratio at various temperatures during TPR-S was compared with the H_2S/H_2 ratios at which NiS and Ni_3S_2 , and Ni_3S_2 and Ni are at thermodynamic equilibrium. In Fig. 11, the experimentally determined H_2S/H_2 ratios are plotted together with the equilibrium values reported by Rosenq-

vist (18). It is clear that the first step (NiS to Ni_3S_2) is determined by kinetics while the second step (Ni_3S_2 to Ni^0) is determined by thermodynamics. These conclusions indicate that our deconvolution procedure was correct.

 WS_2 . The reaction observed above 1000 K is due to the reduction of WS₂ to W. This is not surprising since no intermediate sulfides are known to exist between WS₂ and W. To verify whether the reduction was determined by the thermodynamics, the equilibrium data were calculated (19). Figure 12 shows that the experimental points (curve a) are situated close to the calculated line (curve c), proving that reduction of WS₂ is determined by thermodynamics under TPR-S conditions. This is analogous to reduction of MoS₂. Because the small H₂ consumption peak around 810 K is observed in the same temperature region where the reduction of WO₃ took place (17), it is ascribed to the reduction of WO₂ formed by reoxidation during storage. The fact that part of the WO₃ survived the resulfiding step at 673 K indicates that the reoxidation was not restricted to the surface layers.

Catalysts

W(2.4)/Al. The experimental H_2S/H_2 ratio under TPR-S conditions of W(2.4)/Al which was sulfided at 873 K is plotted in Fig. 12 (curve b). Above 1000 K, it is situated closely to the curve corresponding with the ther-

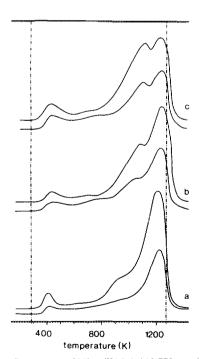


FIG. 8. TPR-S patterns of Ni(x)/W(2.3)/Al-773 catalysts which are sulfided at 673 K. (a) Ni(1.0)/W(2.3)/Al-773, (b) Ni(2.0)/W(2.3)/Al-773, (c) Ni(2.9)/W(2.3)/Al-773. UV signal (lower curve) and TCD signal (upper curve) are shown.

TABLE 4
H ₂ S Production and H ₂ Consumption in TPR-S of Sulfided Ni(x)/W(2.3)/Al Catalysts Calcined at 773 and 1073 K

Catalyst	Sulf. temp	Amount (μmol)		Region I (µmol)		Region II (µmol)		Region III (µmol)		5.164
	(K)	Ni	W	H ₂ S	H ₂	H ₂ S	H ₂	H ₂ S	H ₂	Sulf. ^a (%)
Ni(1.0)/W(2.3)/Al-773	673	27	63	2.4	7.1	12	13	73	146	51
Ni(1.0)/W(2.3)/Al-1073	673	27	63	5.1	4.5	16	~0	56	168	39
Ni(2.0)/W(2.3)/Al-773	673	54	61	5.3	5.8	20	10	105	170	66
Ni(2.0)/W(2.3)/Al-1073	673	54	61	4.8	4.8	18	~0	60	188	38
Ni(2.9)/W(2.3)/Al-773	673	78	60	8.9	10	24	18	112	174	65
Ni(2.9)/W(2.3)/Al-1073	673	78	60	7.0	6.3	16	6.8	50	223	29

Note. The data are normalised to 0.1 g of catalyst.

modynamic equilibrium of WS₂ and W⁰. This is remarkable, because from the results of Breysse *et al.* (20), it is reasonable to assume that on the catalysts studied, WS₂ slabs are present with very limited degree of stacking. Apparently, in spite of the high dispersion, WS₂ slabs behave like bulk WS₂. The underlying reason might be that bulk WS₂ consists of "WS₂" layers, which are only weakly bonded to each other. Consequently, a single slab

behaves quite similarly to the bulk. The shift of the reduction maximum towards higher temperatures when the sulfiding temperature is increased is due to the presence of different amounts of WS₂ on these catalysts (the higher the sulfiding temperature, the larger the amount of WS₂) and not to a different slab size or interaction strength

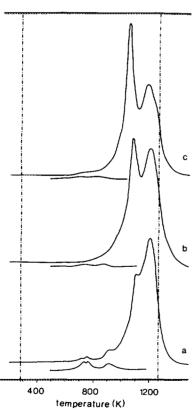


FIG. 9. TPR patterns of Ni(x)/W(2.3)/Al-1073 catalysts. (a) Ni(1.0)/W(2.3)/Al-1073, (b) Ni(2.0)/W(2.3)/Al-1073, (c) Ni(2.9)/W(2.3)/Al-1073. FID signal (lower curve) and TCD signal (upper curve) are shown.

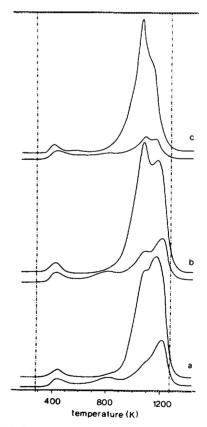


FIG. 10. TPR-S patterns of Ni(x)/W(2.3)/Al-1073 catalysts sulfided at 673 K. (a) Ni(1.0)/W(2.3)/Al-1073, (b) Ni(2.0)/W(2.3)/Al-1073, (c) Ni(2.9)/W(2.3)/Al-1073. UV signal (lower curve) and TCD signal (upper curve) are shown.

^a The degree of sulfiding is calculated as follows: sulfiding degree = 100(x/(2y + 2/3z)), $x = H_2S$ production in region III, y = amount of W, z = amount of Ni.

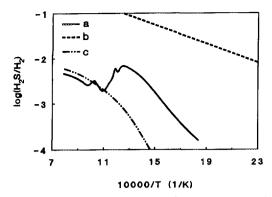


FIG. 11. Comparison of the H_2S/H_2 ratio during the TPR-S experiments of NiS (a) with the H_2S/H_2 ratio at thermodynamic equilibrium of NiS and Ni₃S₂ (b) and Ni₃S₂ and Ni⁰ (c). The curve for the reduction of NiS to Ni₃S₂ is extrapolated to lower temperatures.

of the WS₂ slabs with the support. This illustrates the necessity of carrying out thermodynamic calculations to avoid errors that are easily made.

As the reduction above 1000 K is ascribed to the reduction of the WS₂ slabs, the degree of sulfiding is calculated on the basis of the amount of H_2 consumed and H_2S produced in this temperature region. The low degree of sulfiding (WS_{0.48}) after sulfiding at 573 K agrees with the literature (8). After sulfiding at 873 K, the S/W ratio approached the stoichiometric ratio of 2. As already suggested previously (8), the low sulfiding rate of the alumina-supported WO₃ species is due to their strong interaction with the support.

The experimental H₂S/H₂ ratios below 1000 K are higher than at equilibrium, confirming that the H₂S produced below this temperature is not due to reduction of stoichiometric WS₂. From the fact that in region II the H₂S production is larger than the H₂ consumption we conclude that the H₂S produced in this region is due to recombination of S-H groups and reaction of S-H groups with hydrogen. The presence of S-H groups on similar catalysts is supported by Raman spectroscopy (21). The large amount of S-H groups on the catalysts which were sulfided at low temperatures (573 and 673 K) suggests that S-H groups are formed on oxidic or oxysulfidic species. At higher sulfiding temperatures smaller amounts of S-H groups are present, probably because they recombine, resulting in the formation of H₂S while a sulfur ion is left behind in the oxysulfidic structure (21, 22).

The H_2 consumption and H_2S production observed at about 440 K is ascribed to the reduction of a nonstoichiometric sulfur species. Such a reactive type of sulfur has been reported previously (14, 15, 23), and has been referred to as S_x . It was concluded that these sulfur species were chemisorbed on coordinatively unsaturated sites. It is interesting that the amount of S_x increased with increasing sulfiding temperature. Due to the increased degree of

sulfiding at higher temperatures, the number of WS₂ slabs increased and apparently simultaneously the amount of coordinatively unsaturated edge/corner sites increased.

Ni(x)/Al. For a detailed description of the structure of NiO/Al catalysts we refer to papers by Scheffer *et al.* (7, 9), Puxley *et al.* (24), and de Korte *et al.* (25). Since the structure of these catalysts has been studied in detail with TPR (7), the various reduction peaks are assigned without extensive discussion. In the TPR patterns of the Ni(x)/Al calcined at 773 K the peaks have been assigned to species as follows:

- (a) The reduction peak between 700 and 1000 K is ascribed to a highly dispersed NiO surface phase (in Refs. 7 and 9 referred to as phase II). The width of this peak suggests a rather poorly defined phase consisting of Ni species with a small, variable amount of Al³⁺ neighbours. The Ni ions are octahedrally coordinated.
- (b) The peak between 1000 and 1200 K is ascribed to reduction of highly disperse NiO with a stoichiometry close to NiAl₂O₄. Compared to the disperse NiO phase, these Ni ions are surrounded by a higher number of Al³⁺ ions (in Refs. 7 and 9, denoted as phase IIIa). Since the calcination temperature of 773 K is too low for extensive diffusion, the Ni²⁺ ions are located at the surface. Using diffuse reflectance spectroscopy it has been shown that these Ni ions are octahedrally coordinated (9).

Calcination at 1073 K resulted in the disappearance of the highly dispersed NiO surface species. The sharp peak around 1170 K indicates that Ni is present in a rather well-defined phase. It is concluded that calcination at 1073 K causes extensive diffusion of Ni into the alumina lattice, resulting in a diluted NiAl₂O₄ phase, and both octahedrally and tetrahedrally coordinated Ni ions are formed (in Refs. 7 and 9 denoted as phase IIIb). The absence of a reduction peak at about 600 K indicates that no large NiO crystallites were present on any of these catalysts (7).

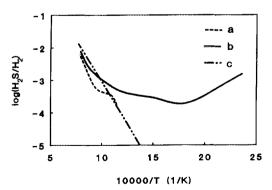


FIG. 12. Comparison of the actual H_2S/H_2 ratio during the TPR-S experiments of WS_2 (a) and W(2.4)/Al (b) sulfided at 873 K with the theoretical H_2S/H_2 ratio at thermodynamic equilibrium of WS_2 with W metal (c).

Comparison of the TPR and TPR-S patterns directly shows that Ni present in the diluted NiAl₂O₄ phase (phase IIIb) is not sulfidable while Ni present in the surface NiAl₂O₄ phase (phase IIIa) is hardly sulfidable. The fact that the diluted NiAl₂O₄ phase is not sulfidable at industrially common sulfiding temperatures has also been reported by others (8, 26). Because diffusion of the Ni ions back to the surface layer is very slow at these temperatures, sulfiding is excluded.

The major part of the surface NiAl₂O₄ species (phase IIIa) is not sulfidable at generally applied sulfiding conditions. Apparently, the O-S exchange, essential for sulfiding, is not possible, probably because all oxygen atoms surrounding the Ni are also coordinated to the Al³⁺ ions.

After sulfiding at 673 K the reduction peak of the dispersed NiO surface species has nearly completely disappeared, indicating that this phase is easy to sulfide. On the basis of the Ni-S phase diagram (18) it is expected that the NiO species are sulfided to NiS_{1+x}. Formation of NiS, under comparable sulfiding conditions, has also been reported elsewhere (8, 10). On the basis of the quantitative data (H₂ consumption and H₂S production), it is concluded that after sulfiding the major part of the sulfided Ni species was present as NiS_{1+x} microcrystallites. Analogous to bulk NiS, reduction of these crystallites took place in two steps, viz. the first step of NiS_{1+x} to Ni_3S_2 at 500 K and the second step Ni₃S₂ to Ni⁰ above 800 K. On the basis of TPS measurements, Scheffer et al. (8) concluded that two types of sulfided Ni species were present, viz., NiS_{1+x} microcrystallites and ultra-dispersed sulfided NiO species stabilised by Ni-O-Al links against sintering and reduction. The latter will not reduce in two steps as observed for crystallites. The percentage of Ni present as dispersed sulfided NiO species cannot be deduced from these patterns. Thermodynamic analysis shows that Ni₃S₂ particles and dispersed nickel sulfide species are more stable than bulk Ni₃S₂. Apparently, they are small enough to experience significant active phase support interaction causing an increased stability.

The amount of H_2S produced at low temperatures (500 K) is larger than the amount calculated according to the reduction of NiS_{1+x} into Ni_3S_2 . Probably, the 500 K peak is the result of reduction of both NiS_{1+x} and chemisorbed S species, similar to the S_x species observed for the W(2.4)/Al-773 catalyst. As the reduction of these S_x species is also observed on the nonsulfidable Ni(x)/Al-1073 catalysts, we conclude that chemisorption of these sulfur species is not restricted to sulfided Ni but can also take place on coordinatively unsaturated oxidic Ni species. The increase of the amount of S_x with increasing Ni content on these catalysts confirms that the S species adsorb on exposed Ni ions rather than on the support. Figure 6 shows that for the catalysts calcined at 1073 K the reduction of these sulfur species is taking place at 540 K instead

of 500 K as observed on the catalysts calcined at 773 K. The shift of the reduction temperature probably reflects the stronger interaction of the S_x species with the oxidic catalyst: the Ni ions in the surface NiAl₂O₄ layer are polarised by Al³⁺ ions, resulting in a stronger interaction with the adsorbed sulfur atoms. These S_x species are formed by decomposition of H_2S on the coordinatively unsaturated Ni ions.

Ni(x)/Al. Alumina-supported NiO-WO₃ catalysts have been studied in detail by TPR by Scheffer *et al.* (7). Hence, assignment of the various TPR peaks is based partly on their interpretation (7). At least four phases which reduce in three different temperature regions are detected on the catalysts calcined at 773 K as summarised in the following:

- (a) The peak between 700 and 1000 K, which was also observed during the reduction of the Ni(x)/Al-773 catalysts, is ascribed to the reduction of the highly dispersed NiO surface species. The presence of this phase is not surprising since at a loading of 2.3 at/nm² not all the alumina is covered with WO₃ (a monolayer is formed at a W loading of approx. 4.3 at/nm²) (2).
- (b) The peak between 950 and 1100 K is due to the reduction of surface NiAl₂O₄ (phase IIIa). In addition, the reduction of a mixed NiO-WO₃ phase (indicated as NiWOAl by Scheffer *et al.* (7, 9)) takes place in this temperature region. The presence of such a ternary compound has also been reported by others (2, 28).
- (c) The peak at about 1200 K is ascribed to the reduction of the WO₃ monolayer, and the decreased intensity with increasing NiO content indicates that part of the WO₃ species reduced at lower temperatures. This is not surprising since incorporation of Ni in the WO₃ monolayer results in a decrease of the number of Al neighbours of the W ions which causes a more easy reduction of a part of the WO₃ species. The TPR peak is accordingly very broad, as expected for such an ill-defined structure with varying coordination.

Calcination of these catalysts at 1073 K resulted in the following changes:

- (i) The peak between 700 and 1000 K disappeared completely, obviously because the dispersed NiO phase reacted into a more stable phase.
- (ii) Between 1050 and 1100 K, a sharp peak is observed which is ascribed to the reduction of NiWO₄. The sharpness of this latter peak suggests a well-defined phase. Since XRD did not reveal any crystalline phase it is concluded that Ni is present in microcrystalline NiWO₄ particles. In agreement herewith, the intensity of the reduction peak of the WO₃ monolayer species at 1200 K is strongly decreased. The formation of NiWO₄ microcrystallites, at higher calcination temperatures, was also observed by

Iannibello et al. (29). Scheffer et al. (7) have reported that the formation of this phase is thermodynamically more favourable than the formation of NiAl₂O₄.

The TPR-S patterns are quite complex. It is easiest to start the discussion with the highest temperature peak. Both the TCD and UV peak are also found in the TPR-S patterns of W/Al. The peaks at the highest temperature (1200 K) are due to reduction of WS₂ and WO₃. The height of the H₂S peak is only slightly affected by the presence of Ni, indicating that the sulfiding degree of the WO₃ species is not altered significantly. Only part of the tungsten (WO₃ and WS₂) is reduced in this peak, the other part being reduced in the peak at 1050 K. Since all sulfided W species reduce at about 1200 K, the W species that are reduced at 1050 K should be in their oxidic state. We conclude that W is here present as a mixed nonsulfided Ni-W phase (NiWOAl), also because with increasing Ni content this peak increases while the highest temperature TCD peak decreases.

The H₂S production peak with a maximum between 900 and 1100 K is ascribed to a contribution of the reduction of nickel sulfide and Ni located at the edges of WS₂ slabs. In analogy with "CoMoS" we denote these species as NiWS. The experimental H₂S/H₂ ratios are compared with the thermodynamic data with respect to NiS \rightarrow Ni₃S₂ and $Ni_3S_2 \rightarrow Ni$ in Fig. 13. Remarkably, the points of the peak between 900 and 1100 K are situated close to the reduction curve of Ni₃S₂. Apparently, reduction of Ni₃S₂ is taking place. At first sight this is surprising, because it is generally accepted that sulfiding of supported CoMo, NiMo, CoW, and NiW catalysts results in the formation of the so-called CoMoS, NiMoS, CoWS, and NiWS phases, respectively. Since the precursor of the NiWS phase, the NiWOAl phase, was present on the catalyst, we may assume that a large part of the Ni was present as NiWS after sulfiding. It is quite striking that no separate reduction peak of Ni situated on the edges of the WS₂ slabs is

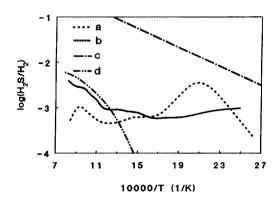


FIG. 13. Comparison of the experimental H_2S/H_2 ratio during the TPR experiments of sulfided Ni(2.6)/Al-773 (a) and Ni(2.9)/W(2.3)/Al-773 (b) with the theoretical H_2S/H_2 ratio at thermodynamic equilibrium of NiS with Ni₃S₂ (c) and Ni₃S₂ and Ni metal (d).

observed; it is certainly not expected, a priori, that the reduction behaviour of the NiWS phase would be similar to Ni₃S₂. This contradiction can be explained as follows. Before the reduction temperature of this phase is reached, sintering occurs, resulting in the formation of Ni₃S₂ and WS₂, and, hence, in a strong decrease of the amount of NiWS. Deconvolution of the Ni₃S₂ and WS₂ peaks indicates a slight increase of the amount of sulfidable Ni species compared to Ni in the Ni(x)/Al-773 catalysts. Apparently, part of the Ni present in the NiWOAI phase is better sulfidable than Ni surface and subsurface spinels in Ni(x)Al catalysts. However, as was already mentioned, a part of this NiWOAl phase is not sulfidable at 673 K. Most probably, NiO species present on the WO3 monolayer are easily sulfidable whereas the sulfidability of the Ni species is low when these ions are incorporated in the WO₃ monolayer. This conclusion is supported by the TPR-S measurements of the Ni(x)/W(2.3)/Al catalysts calcined at 1073 K. The degree of sulfiding of these catalysts decreased significantly, although Ni and W species were still present as dispersed phases (no XRD peaks from crystalline NiO, WO₃, or NiWO₄). The degree of sulfiding of the Ni and W species became even lower than that of the monometallic catalysts. Since the NiWO₄ is not sulfided at 673 K, it is plausible that sulfiding of Ni is strongly retarded by incorporation in the WO3, monolayer. Results of Scheffer et al. (8), who showed that NiWO₄ sulfided only above 900 K, agree with our conclusion that NiWO₄ is not sulfidable at 673 K.

Analogously to Ni(x)/Al-773, sulfiding of Ni(x)/W(2.3)/Al-773 resulted in the complete disappearance of the H_2 consumption of the dispersed NiO phase (in TPR), confirming that this phase is completely sulfidable at 673 K.

Since the interpretation is rather complicated, the various phases present after sulfiding at 673 K are indicated in the TPR-S pattern of the Ni(2.0)/W(2.3)/Al-773 catalysts (Fig. 14). The UV peak at 1200 K is ascribed to the reduction of WS₂. The amount of H₂ required to reduce this phase is indicated in the TCD pattern. The remaining H₂ consumption at 1200 K is caused by reduction of dispersed WO₃. Between 800 and 1100 K reduction of Ni₃S₂ takes place. Despite the fact that reduction of NiWS is not observed due to sintering (NiWS \rightarrow Ni₃S₂ + WS₂), the reduction of NiWS is indicated. The amount of H₂ consumed to reduce Ni₃S₂ is indicated in the TCD pattern. The additional amount of H₂ is assigned to reduction of nonsulfided NiAl₂O₄ and NiWOAl species. Analogous to the TPR-S patterns of the W(2.3)/Al catalysts the H₂S production and corresponding H₂ consumption in region II are the result of recombination of S-H groups and reaction of H_2 and S-H groups. Similar to Ni(x)/Al and W(2.4)/Al catalysts, reduction of S_x species is observed in region I. The reduction occurs at a temperature lower than with Ni(x)/Al, and also slightly lower than with

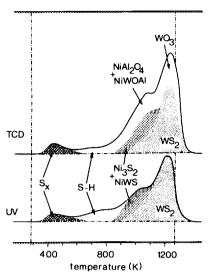


FIG. 14. The various phases present after sulfiding NiW catalysts at 673 K are indicated in the TPR-S pattern of Ni(2.0)/W(2.3)/Al.

W(2.3)/Al catalysts. Because reduction of S might be an elementary step in HDS, the reduction rate of the S_x species might be correlated to the desulfurisation activity. The order of activity of Ni, W, and Ni–W based catalysts was Ni < W \leq Ni–W (30). The reduction temperature of S_x decreases in the same order. However, the reduction temperature of these species differs only slightly for the W and Ni–W catalysts, whereas the activity of these catalysts differs by one order of magnitude. Hence, the reduction temperature of S_x and HDS activity are only weakly correlated. Thus it is not likely that the reaction of S with H_2 to H_2S on W and NiW catalysts is the rate-limiting step in HDS. The analogous conclusion has been drawn for Co–Mo catalysts (15).

CONCLUSIONS

Detailed information about the sulfidability of the various species in alumina-supported Ni, W, and Ni-W catalysts is obtained by combination of the TPR patterns of the oxidic and sulfidic catalysts.

The following phases have been found in the oxidic catalysts: a highly dispersed NiO surface phase, surface, and subsurface NiAl $_2$ O $_4$ -like phases, dispersed WO $_3$, a mixed NiO-WO $_3$ phase (NiWOAl) and dispersed NiWO $_4$ crystallites.

The major part of the dispersed species present on Ni/Al catalysts, calcined above 773 K, is not sulfidable at industrial sulfiding temperatures (<673 K). Only the dispersed Ni²⁺ surface phase is completely sulfidable at this temperature.

W/Al catalysts (2.4 at/nm²) are only partly sulfided at commonly applied sulfiding temperatures; the degree of

sulfiding increased from ± 24 to 95% upon an increase of the sulfiding temperature from 573 to 873 K.

The mixed Ni-W phase is partly sulfided at 673 K, depending on the speciation of the Ni ions; Ni ions located at the WO₃ monolayer are sulfided, while Ni ions incorporated in the WO₃ monolayer are not. The sulfidability of the WO₃ monolayer is only slightly affected by the presence of Ni. NiWO₄ which is formed after calcination at 1073 K is not sulfidable at 673 K.

Reduction of bulk WS₂ took place in one step between 1000 and 1270 K, and the rate was determined by thermodynamics. Bulk NiS reduced in two steps, viz. NiS to Ni₃S₂, and Ni₃S₂ to Ni⁰. The rate of the first step was determined by kinetics and that of the second by thermodynamics.

 WS_2 slabs formed during sulfiding of W/Al catalysts are reduced above 1000 K at a rate determined by bulk thermodynamics. The reduction of the NiS_{1+x} species is divided into two categories, viz., the reduction of microcrystalline NiS_{1+x} , which is reduced in two steps similar to the reduction of bulk NiS, and ultra-dispersed nickel sulfide which is reduced in one step above 900 K. The reduction of the NiWS phase is not observed due to sintering during the temperature program, leading to Ni_3S_2 and WS_2 .

After sulfiding at 673 K, a small part of the sulfur is present as S-H groups.

On all catalysts, the reduction of a nonstoichiometric phase (S_x) is observed, which is chemisorbed on coordinatively unsaturated sites. The chemisorption of these sulfur atoms is not restricted to sulfides but can also take place on oxidic material. Despite the fact that the reduction of these sulfur species took place below HDS reaction temperatures, only a weak correlation existed between the HDS activity and the reduction temperature. Under HDS conditions, hydrogenation of S is not the rate-limiting step for alumina-supported NiW catalysts.

ACKNOWLEDGMENT

Financial support from the EC under contract number 704F0049 is gratefully acknowledged.

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